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Bandgap engineering and structure analysis of ZnO/ Al₂O₃ superlattices grown by atomic layer deposition. W.C. HSIEH, Q.Y. CHEN, P.V. WADEKAR, C.F. CHANG, Department of Physics, National Sun Yat-Sen University, H.C. HUANG, Department of Material Science and Optoelectronics, National Sun Yat-Sen University, C.M. SHIAU, Y.P. CHENG, Y.S. HONG, C.Y. DANG, P.C. KUNG, C.H. LEE, S.H. HUANG, Z.Y. WU, Y.Y. LIANG, C.M. LIN, S.T. YOU, L.W. TU, Department of Physics, National Sun Yat-Sen University, N.J. HO, Department of Material Science and Optoelectronics, National Sun Yat-Sen University, H.W. SEO, Department of Physics, Jeju National University, W.K. CHU, Texas Center of Superconductivity and Department of Physics, University of Houston — ALD-grown ZnO/Al₂O₃ superlattices (SLS) as analyzed by XRR assisted with GenX fittings exhibit a consistent mass density for the ZnO layers of 5.6 g/cm³, largely that of the bulk crystal. However, for Al₂O₃, the value is ~2.95 g/cm³ versus the ideal 3.95 g/cm³. This discrepancy suggests a highly porous Al₂O₃, possibly due to the presence of hydrogen in an AlO(OH) amorphous boehmite phase. TEM imaging portrays the periodic structures consistent with the XRR findings. The ZnO layers are c-textured while Al₂O₃ amorphous. Room-temperature CL measurements showed decreasing ZnO bandgap as the Al₂O₃ cycles increased, hinting at feasible bandgap engineering through SLS structural variations. Amorphous Al₂O₃ is known to have a smaller bandgap of 5.7-7.1 eV as compared to 7.1-8.8 eV for bulk crystals. CL also showed a peak at ~5.1 eV, thus consistent with our conjecture of the am-Al₂O₃.

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